

Video Article

Key Factors Affecting the Performance of Sb₂S₃-sensitized Solar Cells During an Sb₂S₃ Deposition *via* SbCl₃-thiourea Complex Solution-processing

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Abstract

Sb₂S₃ is considered as one of the emerging light absorbers that can be applied to next-generation solar cells because of its unique optical and electrical properties. Recently, we demonstrated its potential as next-generation solar cells by achieving a high photovoltaic efficiency of > 6% in Sb₂S₃-sensitized solar cells using a simple thiourea (TU)-based complex solution method. Here, we describe the key experimental procedures for the deposition of Sb₂S₃ on a mesoporous TiO₂ (mp-TiO₂) layer using a SbCl₃-TU complex solution in the fabrication of solar cells. First, the SbCl₃-TU solution is synthesized by dissolving SbCl₃ and TU in *N,N*-dimethylformamide at different molar ratios of SbCl₃:TU. Then, the solution is deposited on as-prepared substrates consisting of mp-TiO₂/TiO₂-blocking layer/F-doped SnO₂ glass by spin coating. Finally, to form crystalline Sb₂S₃, the samples are annealed in an N₂-filled glove box at 300 °C. The effects of the experimental parameters on the photovoltaic device performance are also discussed.

Video Link

The video component of this article can be found at <https://www.jove.com/video/58062/>

Introduction

Antimony-based chalcogenides (Sb-Chs), including Sb₂S₃, Sb₂Se₃, Sb₂(S,Se)₃, and CuSbS₂, are considered to be emerging materials that can be used in next-generation solar cells^{1,2,3,4,5,6,7,8}. However, photovoltaic devices based on Sb-Chs light absorbers have not yet reached the 10% power conversion efficiency (PCE) required to demonstrate feasible commercialization.

To overcome these limitations, various methods and techniques have been applied, such as a thioacetamide-induced surface treatment¹, a room temperature deposition method⁴, an atomic layer deposition technique², and the use of colloid dot quantum dots⁶. Among these various methods, the solution-processing based on a chemical bath decomposition exhibited the highest performance¹. However, a precise control of the chemical reaction and the post-treatment are required to achieve the best performance^{1,3}.

Recently, we developed a simple solution-processing for high-performance Sb₂S₃-sensitized solar cells using a SbCl₃-thiourea (TU) complex solution³. Using this method, we were able to fabricate a quality Sb₂S₃ with a controlled Sb/S ratio, which was applied to a solar cell to achieve a comparable device performance of 6.4% PCE. We were also able to effectively reduce the processing time since the Sb₂S₃ was fabricated by a single-step deposition.

In this work, we describe the detailed experimental procedure for an Sb₂S₃ deposition on the substrate consisting of mesoporous TiO₂ (mp-TiO₂)/TiO₂ blocking layer (TiO₂-BL)/F-doped SnO₂ (FTO) glass for the fabrication of Sb₂S₃-sensitized solar cells *via* SbCl₃-TU complex solution-processing³. In addition, three key factors affecting the photovoltaic performance in the course of an Sb₂S₃ deposition were identified and discussed. The concept of the method can be easily applied to other sensitizer-type solar cells based on metal sulfides.

Protocol

1. Synthesis of the TiO₂-BL Solution

1. Prepare 2 transparent vials with a 50 mL volume.
2. Add 20 mL of ethanol to 1 vial (V1) and seal V1.
3. Transfer V1 to an N₂-filled glove box with a moisture-controlled system of an H₂O level of < 1 ppm.
4. Add 1.225 mL of titanium (IV) isopropoxide (TTIP) to V1 using a syringe with a 0.45 µm PVDF filter and gently stir the mixture for at least 30 min.

NOTE: This step must be performed in a glove box (or under very low humidity conditions) since TTIP is highly sensitive to moisture. If the TTIP solution is not transparent or white precipitates are observed inside the solution, it should not be used, because an undesirable reaction has already occurred inside the solution.

5. In the other prepared vial (V2), add 18 μL of HNO_3 (70%) and 138 μL of H_2O to 20 mL of ethanol using a micropipette and gently stir the mixture for at least 30 min.

NOTE: This step must not be performed in a glove box, because H_2O is used.

6. Mix the 2 solutions by pouring the V2 solution into the V1 solution and stir for more than 2 h to synthesize the transparent 0.1 M TiO_2 -BL solution.

NOTE: The final solution must be transparent. If the solution is not transparent, resynthesize it until a transparent solution is obtained.

Successfully prepared TiO_2 -BL solutions are stable for several days at humidity conditions of < 50%.

2. Synthesis of the SbCl_3 -TU Solutions with Various SbCl_3 /TU Molar Ratios

NOTE: The synthesis must be performed in the glove box because of the very high sensitivity of SbCl_3 to moisture.

1. Prepare the SbCl_3 stock solution [1 mmol of SbCl_3 in 1 mL of *N,N*-dimethylformamide (DMF)] inside the glove box. For example, add 6.486 g of SbCl_3 to 30 mL of DMF for a 32.2 mL stock solution.
2. Add a proper amount of stock solution to a vial containing a given amount of TU to synthesize the SbCl_3 -TU solution with the desired molar ratio of SbCl_3 /TU. For example, suppose the 2 vials each contain 0.1 g of TU, add 0.9394 mL of the stock solution to one vial and 0.5637 mL to the other, to synthesize solutions with SbCl_3 /TU ratios of 1/1.5 and 1/2.5, respectively.

3. Preparation of the Substrate Consisting of mp- TiO_2 / TiO_2 -BL/FTO Glass

1. Wash the FTO-coated glass (FTO glass) of 25 mm x 25 mm in an ultrasonic bath with acetone for 10 min, followed by ethanol.
NOTE: To fabricate the photovoltaic device, use pre-patterned FTO glass, where the 5 - 10 mm x 25 mm FTO surface is completely etched.
2. Instantly dry the FTO glass by blowing compressed air over the sample.
3. Treat the FTO glass with a UV/O_3 cleaner for 20 min.
4. Spin coat ethanol on the FTO glass at 5,000 rpm for 60 s.
5. Immediately spin coat again with the prepared TiO_2 -BL solution under the same conditions of step 3.4.
6. Dry the FTO glass for 2 min by placing it on a preheated hot plate at 200 $^\circ\text{C}$.
7. Repeat steps 3.5 and 3.6 to obtain the desired TiO_2 -BL thickness.
8. Deposit the mp- TiO_2 layer on the TiO_2 -BL/FTO glass using the screen printing method with TiO_2 paste (50 nm TiO_2 particles) and a polyester mask.
9. Anneal the mp- TiO_2 / TiO_2 -BL/FTO glass at 500 $^\circ\text{C}$ for 30 min.
10. Dip the annealed substrates in a transparent aqueous 40 mM TiCl_4 solution after cooling them to room temperature.
NOTE: The 40 mM TiCl_4 solution must be transparent. If the substrates are dipped in the TiCl_4 solution before they are cooled, they can easily break because of the large temperature difference between the substrate and the solution.
11. Transfer the substrates to an oven at 60 $^\circ\text{C}$ and store them for 1 h.
12. Rinse the substrates several times with warm water and instantly dry them by blowing compressed air on them.
NOTE: To prevent any cracking of the substrates, use warm water (approximately 60 $^\circ\text{C}$) when rinsing.
13. Anneal the substrates again at 500 $^\circ\text{C}$ for 30 min.

4. Deposition of Sb_2S_3 on the Substrate of mp- TiO_2 / TiO_2 -BL/FTO Glass

1. Treat the substrates with a UV/O_3 cleaner for 20 min to clean the surface, and transfer them to the glove box.
2. Spin coat a DMF solvent on the substrates at 3,000 rpm for 60 s prior to spin coating them with the SbCl_3 -TU solution.
3. Heat the as-coated substrates for 5 min by placing them on a hot plate at 150 $^\circ\text{C}$ for a partial thermal decomposition and the amorphous phase formation.
4. Place the samples on a preheated hot plate at 300 $^\circ\text{C}$ for 10 min for the crystalline phase formation.
5. After cooling the samples to room temperature, remove them from the glove box.

5. Fabrication of Sb_2S_3 -sensitized Solar Cells

1. Add 15 mg of poly(3-hexylthiophene) (P3HT) to 1 mL of chlorobenzene and gently stir them until a clear reddish solution is obtained.
2. Spin coat chlorobenzene on the Sb_2S_3 -deposited substrate at 3,000 rpm for 60 s.
3. Immediately spin coat again with the prepared P3HT solution under the same conditions as used in step 5.2.
4. Transfer the samples into a vacuum chamber of the evaporator.
5. Deposit 100 nm gold with a rate of 1.0 $\text{\AA}/\text{s}$.

Representative Results

Figure 1 shows a schematic representation of the experimental procedure for the Sb_2S_3 deposition on the substrate of mp-TiO₂/TiO₂-BL/FTO glass. **Figure 1d** shows the basic properties and scheme of a typical product fabricated by the method described herein. The main X-ray diffraction (XRD) pattern is well matched with that of a stibnite Sb_2S_3 structure^{1,3,4} and impurity phases, such as Sb_2O_3 , are not visible except for substrate phases (denoted as T and F). In addition, the absorption edge at approximately 730 nm, as shown in the inset of the XRD pattern, is consistent with the band gap (E_g) of Sb_2S_3 (1.7 eV)^{1,3,4,9}. These results confirm that quality Sb_2S_3 can be successfully fabricated through the method presented herein.

To fabricate high-performance Sb_2S_3 -sensitized solar cells with a > 5% efficiency using this method, three key deposition steps that significantly affect the quality of the final product should be considered during the Sb_2S_3 deposition. These steps are the TiO₂-BL deposition, the mp-TiO₂ deposition, and the SbCl_3 -TU solution deposition. Here, we show the factors during the Sb_2S_3 deposition that affect the photovoltaic (PV) performance.

In the step of the TiO₂-BL deposition (key step 1), the thickness of TiO₂-BL can be controlled by repeating the two steps of spin coating with the TiO₂-BL solution and drying the substrate. **Figure 2a** shows the cross-sectional field emission scanning electron spectroscopy (FESEM) images of the devices fabricated with different TiO₂-BL thicknesses. The TiO₂-BL thickness linearly increases from 46 to 260 nm as the number of repetition times from 1 to 6 increases, as shown in **Figure 2a** and **2b**. In terms of the PV device performance, as measured by PCE, the highest PCE values were observed at a BL thickness of approximately 130 nm (repetition times of 3).

Figure 3a and **3b** show the cross-sectional FESEM images of substrates with different mp-TiO₂ thickness and their current density-voltage (J-V) curves as a function of mp-TiO₂ thickness, respectively. The mp-TiO₂ thickness is controlled by choosing different mesh types of the polyester mask. As the mesh count (per inch) of the mask increases from 250 to 460, the mp-TiO₂ thickness decreases from 1600 to 830 nm, as shown in **Figure 3a**. The PV performance remained similar in the mp-TiO₂ thickness range of 830 - 1200 nm, but further thickness increase led to a reduced efficiency (**Figure 3b**).

In order to investigate the effects of the SbCl_3 :TU molar ratio in key step 3, the absorption properties of the samples prepared with different molar ratios of the SbCl_3 -TU precursor solutions were examined. As shown in **Figure 4a**, the absorption remarkably increased with a TU increase in ratio to 1:2.0; however, it gradually decreased with further TU content increases. To investigate the change of E_g , Tauc plots derived from the absorption spectra were investigated¹⁰. The result indicates a different $(\text{d}h\nu)^2$ value but the same E_g of 1.7 eV. The best device performance was obtained around the molar ratio of SbCl_3 :TU = 1:2.0³, as shown in **Table 1**.

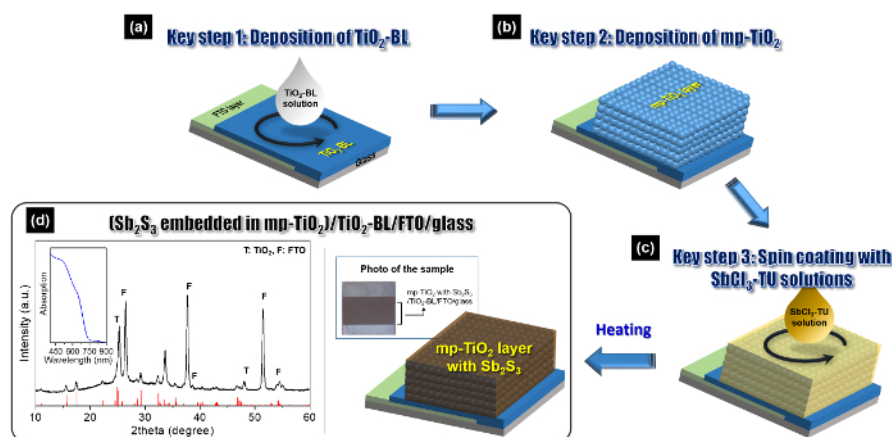


Figure 1: A schematic diagram of the deposition procedure for the Sb_2S_3 deposition on the substrate. (a), (b), and (c) These panels shows the three key experimental steps. (d) This panel shows the resultant sample composed of (mp-TiO₂ with Sb_2S_3)/TiO₂-BL/FTO glass. In the XRD pattern, the standard stibnite Sb_2S_3 structure (JCPDS No. 42-1393) is plotted as the red column. This figure has been modified from Choi *et al.*³. Please click here to view a larger version of this figure.

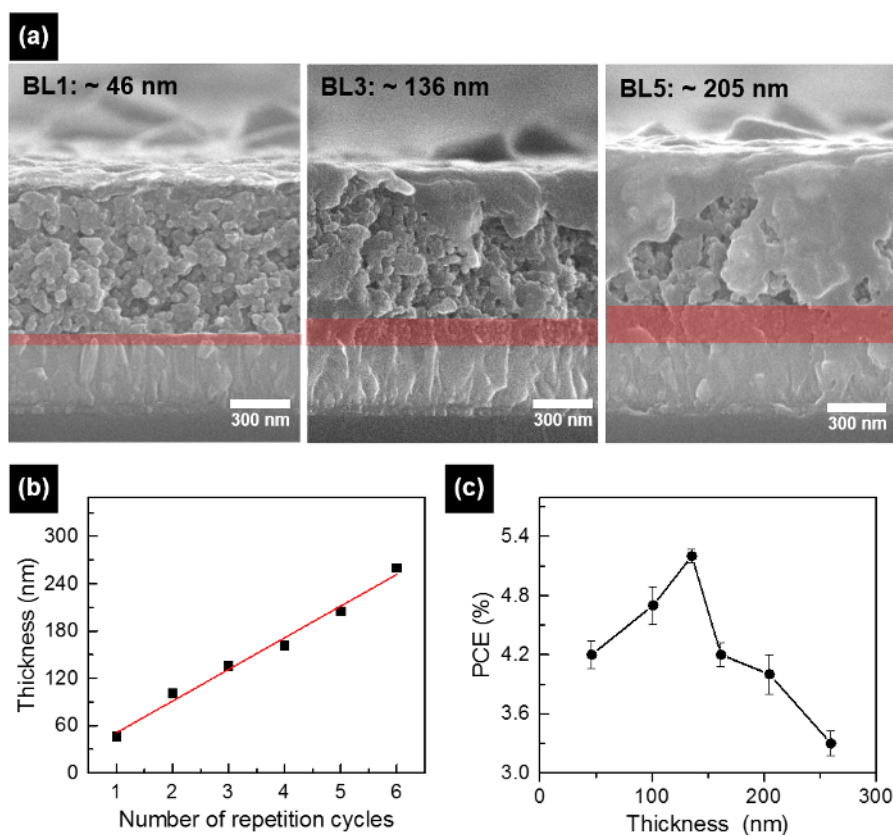


Figure 2: The effects of TiO₂-BL thickness in key step 1. (a) This panel shows cross-sectional FESEM images of photovoltaic devices fabricated with different TiO₂-BL thicknesses. In the images, BL# means the TiO₂-BL fabricated by # of times repetition, and the part of TiO₂-BL is marked with a red rectangle. (b) This graph shows the TiO₂-BL thickness as a function of the repetition number. (c) This panel shows a PCE graph as a function of TiO₂-BL thickness. The symbols and error bars in panel c are averages and standard deviations, respectively, obtained from the PCE data of ten devices. [Please click here to view a larger version of this figure.](#)

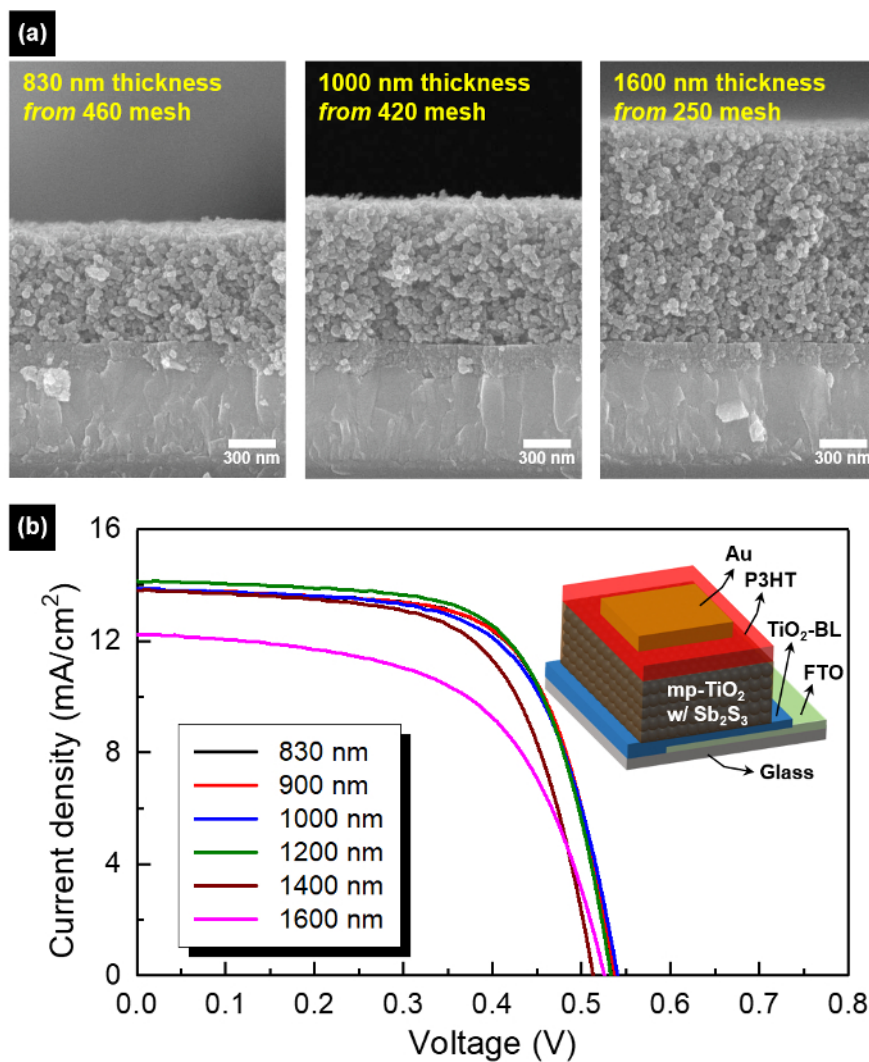


Figure 3: The effects of mp-TiO₂ thickness in key step 2. (a) This panel shows cross-sectional FESEM images of the substrates with different mp-TiO₂ thicknesses. (b) This panel shows a variation of the J-V curves as a function of mp-TiO₂ thickness. [Please click here to view a larger version of this figure.](#)

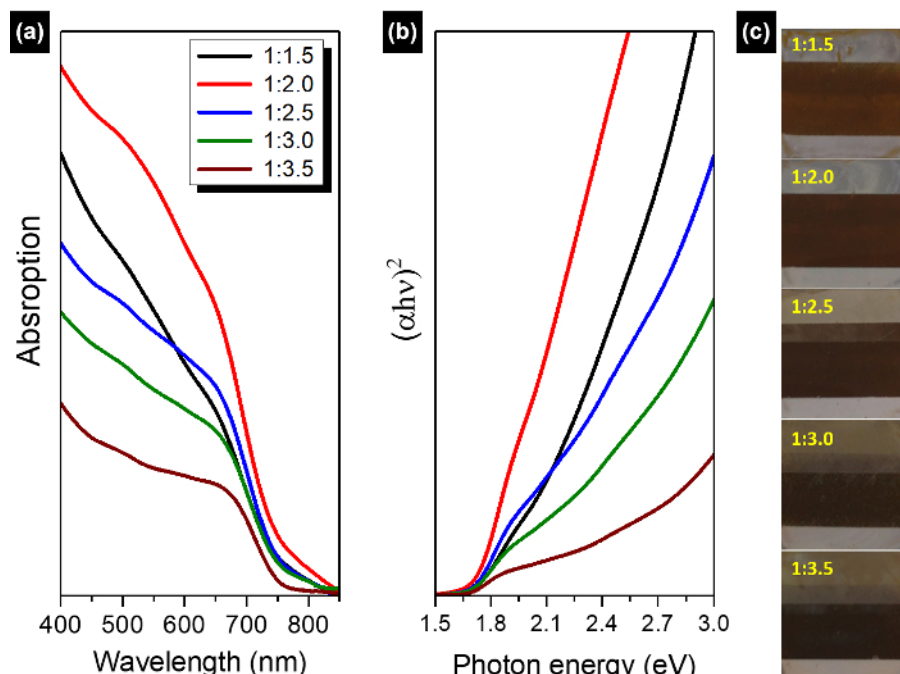


Figure 4: The effects of the molar ratio of SbCl_3/TU in key step 3. These panels show (a) the absorption, (b) the graph of a Tauc plot, and (c) photos of samples fabricated with different SbCl_3/TU molar ratios. The Tauc plot was obtained by assuming that Sb_2S_3 has a direct E_g . [Please click here to view a larger version of this figure.](#)

SbCl_3/TU Ratio	J_{SC} (mA cm^{-2})	V_{OC} (mV)	FF (%)	PCE (%)	$R_{\text{SH}}/R_{\text{S}}$ ($\Omega \text{ cm}^2$)
1:1.4	12.2	475.4	61.7	3.8	582.4/7.1
1:1.6	12	487.4	66.4	4.1	1135.4/6.5
1:1.8	12.7	493.4	66.5	4.4	1217.3/6.8
1:2.0	13.1	493.4	61.6	4.2	644.7/7.8
1:2.2	13	487.4	59.4	3.9	541.8/8.9

Table 1: The effects of the molar ratio of SbCl_3/TU on the photovoltaic performance. J_{SC} , V_{OC} , and FF indicate the short-circuit current density, open-circuit voltage, and fill factor, respectively. The table has been reproduced from Choi *et al.*³.

Supplementary Figure S1: The effects of the presence of mp-TiO₂. These panels show the typical (a) device performance and (b) absorption properties depending on the presence of mp-TiO₂. The samples were fabricated under the same conditions as those used for Figure 2. Mp-TiO₂ with a 1 μm thickness was used for the comparison. [Please click here to download this file.](#)

Discussion

TiO₂-BL is widely used as a hole-blocking layer in solar cells. As shown in Figure 2, a large difference was observed in the device performance depending on the TiO₂-BL thickness. Therefore, its thickness should be optimized to obtain the best overall device performance, because it critically acts as a hole-blocking layer to prevent any direct contact between FTO and hole-transporting materials¹¹. It should be noted that the optimum thickness varies depending on the TiO₂-BL solution species, FTO types, method, light absorbers, and device architectures. In addition to the TiO₂-BL thickness, it should be scanned for annealing conditions including temperature and time in terms of the defect control of TiO₂¹².

In the device created with this protocol, the mp-TiO₂ plays a crucial role in achieving a high performance for two reasons. First, devices with mp-TiO₂ generally have higher J_{SC} values than those without mp-TiO₂, due to the higher absorption characteristics obtained from the Sb_2S_3 deposited on mp-TiO₂, as shown in Supplementary Figure S1. Second, the Sb_2S_3 fabricated via this protocol is easily formed into an island shape rather than a compact thin film on a planar surface¹³. This leads to an undesirable direct contact between the HTM and the TiO₂-BL in planar solar cells. Therefore, it is essential to use mp-TiO₂ in the device introduced here and to find the optimum thickness of mp-TiO₂ for achieving a high performance. For the solar cells fabricated with mp-TiO₂, the mp-TiO₂ thickness is considered as a key factor for obtaining solar cells of high performance and varies depending on the types of materials deposited on the surface of mp-TiO₂. For example, mp-TiO₂ with a thickness of 5 - 30 μm and < 200 nm is typically applied in dye-sensitized¹⁴ and hybrid perovskite solar cells^{15,16,17}, respectively, to achieve a good device performance. In the current Sb_2S_3 -sensitized solar cells, the thickness of mp-TiO₂ of approximately 1 μm is more suitable for the best performance³, but the optimum thickness may vary and mp-TiO₂ may not be needed depending on the method².

Determining the ideal SbCl_3/TU molar ratio is critically important because it strongly affects the absorption properties of the light sensitizer, which are closely related to J_{SC} , as shown in Figure 4. In addition, an optimized ratio can aid in forming high-purity Sb_2S_3 without impurities or

residues. For the samples fabricated with higher TU ratios, elemental sulfur is formed on the surface, which interrupts the charge flow in the device³. Therefore, to obtain improved devices, the molar ratio should be optimized.

In this study, we have demonstrated three key experimental factors in the course of an Sb_2S_3 deposition and their effects on the PV device performance of Sb_2S_3 -sensitized solar cells. The protocol presented here can be applied to other sensitizer type PV systems based on Sb_2Se_3 ⁵, $\text{Sb}_2(\text{S}/\text{Se})_3$ ⁷, and CuSbS_2 ⁸. We strongly believe that this method provides guidance on accessing novel materials for PV systems.

Disclosures

The authors have nothing to disclose.

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